



1202-36,00 (2)  
#17/D  
PATENT APPLICATION  
VDE  
10/31/02

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Arie Hendrik Frans VAN VLIET et al.

Group Art Unit: 1733

Application No.: 09/352,612

Examiner: T. Kilkenny

Filed: July 13, 1999

Docket No.: 102222.01

For: GRID COMPRISING POLYMERIC, DRAWN STRIPS AND A PROCESS  
FOR MAKING SAME

AMENDMENT

Director of the U.S. Patent and Trademark Office  
Washington, D.C. 20231

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In reply to the June 27, 2002 Office Action, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claim 1 as follows:

D1  
1. (Amended) A grid comprising drawn polymeric strips in at least two different directions, wherein the strips have a higher tensile strength in a lengthwise direction of the strips compared to a tensile strength in a width direction of the strips, wherein the strips are bonded together in at least one zone of overlap, which comprises at least two spatially separated bonding points or bonding lines, and wherein the strips comprise a material that absorbs electromagnetic radiation at the at least one zone of overlap.

Please add new claims 19-23 as follow:

D2  
--19. The grid according to claim 1, wherein the strips comprise a layer transparent to electromagnetic radiation and a layer that absorbs electromagnetic radiation.--